



# Comprehensive evaluation factor of optoelectronic properties for transparent conductive metallic mesh films\*

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**Abstract:** Finding the optimal optoelectronic properties (zero-order optical transmittance, shielding effectiveness, and stray light uniformity) of metallic mesh is significant for its application in electromagnetic interference shielding areas. However, there are few relevant studies at present. Based on optoelectronic properties, we propose a comprehensive evaluation factor  $Q$ , which is simple in form and can be used to evaluate the mesh with different parameters in a simple and efficient way. The effectivity of  $Q$  is verified by comparing the trend of  $Q$  values with the evaluation results of the technique for order preference by similarity to ideal solution (TOPSIS). The evaluation factor  $Q$  can also be extended to evaluate the optoelectronic properties of different kinds of metallic meshes, which makes it extremely favorable for metallic mesh design and application.

**Key words:** Metallic mesh; Technique for order preference by similarity to ideal solution (TOPSIS); Entropy weight (EW); Comprehensive evaluation; Transparent conductive films

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## 1 Introduction

With the rapid development of wireless communication technology (Palmer, 2019; Gao et al., 2020; Zhang XX et al., 2020), the electromagnetic environment grows increasingly complex and the need for electromagnetic interference (EMI) shielding is increasingly urgent. EMI shielding of optical transparent windows and components is extremely difficult as there exist inherent conflicts between the high optical transmittance and strong shielding effectiveness (SE) (Lu ZG et al., 2014; Polley et al.,

2014; Wen et al., 2014; Wang HY et al., 2017, 2018). Transparent conductors are one of the most effective methods for EMI shielding for optical transparent elements, and include the metal oxide based transparent conductors (such as ZnO and ITO) (Kim et al., 2005; Zhu M et al., 2007; Greco et al., 2008; Yamada et al., 2008), carbon-based structures (such as nano-tube arrays and graphene films) (Wu ZC et al., 2004; Hecht et al., 2011; Hong et al., 2012; Khrapach et al., 2012; Han et al., 2015; Zhu HX et al., 2019), and metallic networks (such as metallic meshes and silver nanowires) (Kohin et al., 1993; Halman et al., 2009; Madaria et al., 2010; Zeng et al., 2010; Murray et al., 2011; Lu ZG et al., 2014, 2016; Wang HY et al., 2016, 2017, 2018; Wang WQ et al., 2018; Zhu HX et al., 2019; Wu and Cui, 2020; Zhong et al., 2020). Metallic meshes can achieve wideband optical transmittance from the visible to infrared bands, and their use is one of the research hot spots in the field of transparent

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EMI shielding. However, the concentrated stray light caused by mesh diffraction is a serious drawback of these meshes. At present, there are many novel metallic mesh structures which produce a uniform diffraction distribution of stray light (Halman et al., 2009; Murray et al., 2011; Lu ZG et al., 2014, 2016; Wang HY et al., 2016, 2017, 2018; Wang WQ et al., 2018; Zhong et al., 2020). Different meshes have different diffraction characteristics. However, EMI SE and optical transmittance of metallic meshes are mutually restricted. Therefore, to achieve optimal optoelectronic properties (EMI SE, optical transmittance, and stray light uniformity) for metallic meshes, it is necessary to conduct a comprehensive evaluation with different parameters based on these optoelectronic properties. However, so far there have been few studies on this aspect.

In this study, given the contradicting aspects of optoelectronic properties mentioned above in the metallic mesh, a comprehensive evaluation factor  $Q$  is proposed to evaluate the optoelectronic properties. The typical comprehensive evaluation (CE) process of the technique for order preference by similarity to ideal solution (TOPSIS) based on the entropy weight (EW), which has no strict rules and is suitable for evaluating multiple criteria, is used to verify the validity of  $Q$ . In addition, we use  $Q$  to describe five different mesh structures. We show that  $Q$  can be further extended to evaluate the performance of different metallic meshes. Therefore, this comprehensive evaluation method should be of great significance for metallic mesh design and application, since it can be used to obtain the optimal mesh structure and mesh parameters, providing a time-saving and cost-efficient method for optoelectronic property evaluation of the metallic mesh.

## 2 Contradiction analysis of optoelectronic properties for the metallic mesh

For a mesh, there is a close link between structural parameters and optoelectronic properties. The main structural parameters of the mesh are its period and fabricated linewidth, i.e.,  $g$  and  $2a$  respectively, as shown in Fig. 1a, for the most typical single-layer square metallic mesh (SSMM). These determine the main optoelectronic properties, including EMI SE,

optical transmittance or zero-order optical transmittance, and stray light uniformity.

According to the classical metallic mesh analytical models (Kohin et al., 1993; Tan and Lu, 2007; Tan and Liu, 2008), zero-order optical transmittance, EMI SE, and stray light uniformity of the SSMM are calculated as shown in Figs. 1b–1d. From the scalar diffraction theory, zero-order optical transmittance of a mesh is the square of its total optical transmittance. The total optical transmittance is approximately the ratio of the non-metal covered area to the total area. However, in visual imaging application, only the zero-order light is favorable for imaging, while other high-order diffraction light contributes to stray light, which can degrade image quality and the signal-to-noise ratio. Therefore, zero-order optical transmittance is used to evaluate optical transmission characteristics.

Since stray light cannot be eliminated, the high-order diffraction energy should be distributed as uniformly as possible. The stray light uniformity  $U$  is defined as the whole intensity of stray light divided by the maximum of high-order diffraction intensity. According to the relationship between stray light and zero-order optical transmittance, the whole intensity of stray light  $X$  can be expressed as follows:

$$X = I(\sqrt{T_0} - T_0), \quad (1)$$

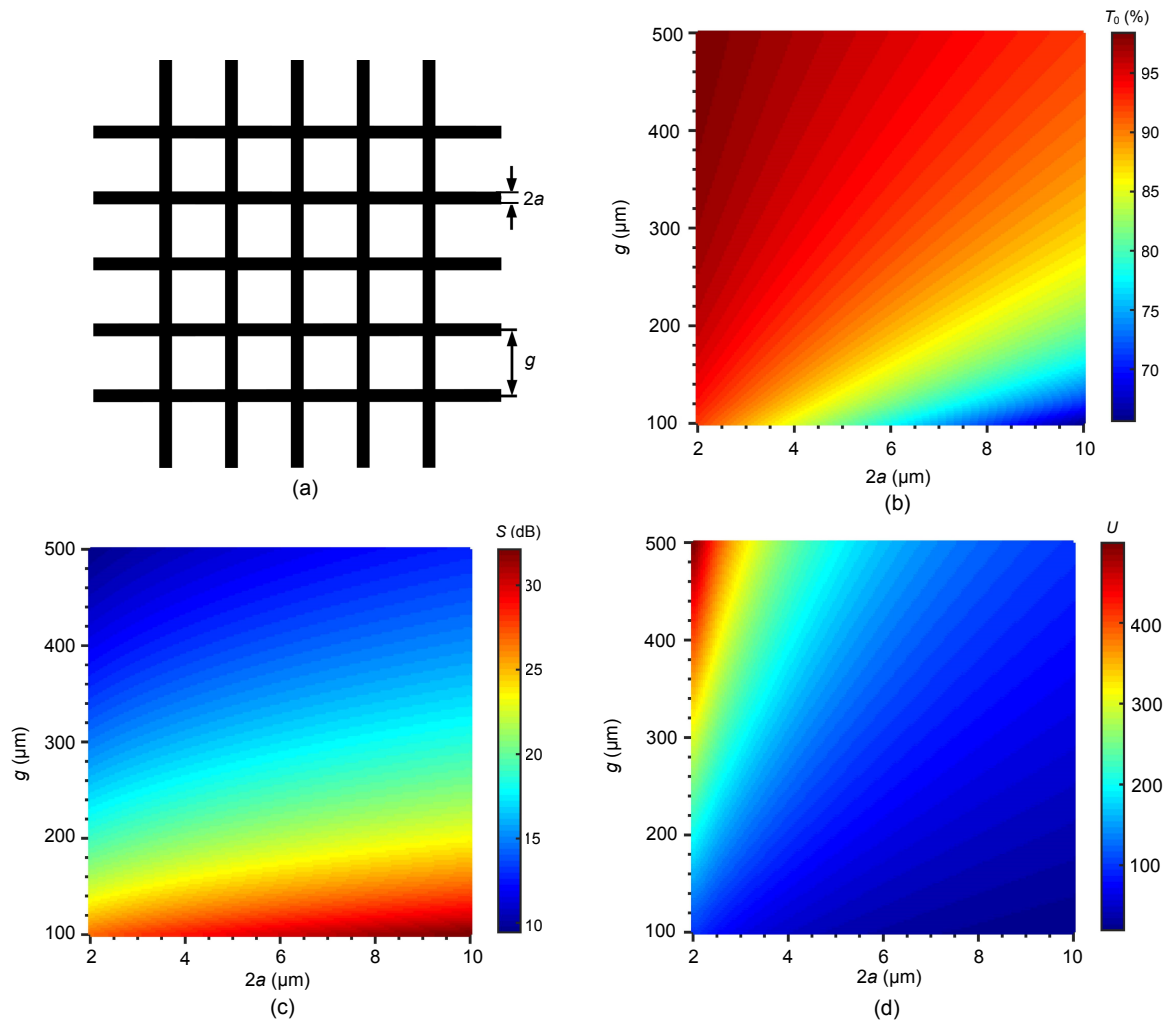
where  $I$  is the incident optical intensity,  $T_0$  is the zero-order optical transmittance, and  $\sqrt{T_0}$  is the total optical transmittance. Thus,  $I(\sqrt{T_0} - T_0)$  represents the whole intensity of stray light.

The stray light uniformity  $U$  can be expressed as

$$U = \frac{X}{DI} = \frac{I(\sqrt{T_0} - T_0)}{DI} = \frac{\sqrt{T_0} - T_0}{D}, \quad (2)$$

where  $D$  is the maximum of the normalized high-order diffraction. According to Eq. (2), the increase of  $U$  means that the proportion of  $D$  in the whole stray light intensity decreases, indicating that the stray light is more uniform. Here, we use  $U$  to evaluate the diffraction characteristics of metallic meshes.

Fig. 1 shows that with the decrease of linewidth  $2a$  or the increase of period  $g$ , zero-order optical



**Fig. 1** Diagram of the square metallic mesh (a) and relationships between the optoelectronic properties and the structural parameters of SSMM: zero-order optical transmittance (b); EMI SE (c); stray light uniformity (d)

transmittance and stray light uniformity decrease, which is beneficial to imaging applications. However, the trend of EMI SE is opposite to that of zero-order optical transmittance. Because the ideal metallic mesh would achieve strong EMI SE, high zero-order optical transmittance, and good stray light uniformity simultaneously, there is a conflict between EMI SE and zero-order optical transmittance in the selection of mesh structural parameters.

In addition, under the premise of the same light transmittance, SE and stray light uniformity of different meshes can vary greatly. Therefore, it is necessary to design a comprehensive evaluation factor for optoelectronic properties, so as to achieve an optimal balance in its performance.

### 3 Comprehensive evaluation factor $Q$ for optoelectronic properties of the metallic mesh

To evaluate the quality of different mesh structures and parameters, based on the above three important optoelectronic properties, we propose a CE standard by defining a comprehensive evaluation factor  $Q$ , similar to the “quality factor” in the circuit and factor  $Q$  in the literature (Rhodes, 1972; Hornig et al., 2003; Vorobyev, 2011).  $Q$  is expressed as follows:

$$Q = \sqrt{T_0} SU, \quad (3)$$

where  $S$  is the EMI SE.  $T_0$ ,  $S$ , and  $U$  can be obtained

by experimental measurement or calculated by the specific mesh period and linewidth. From the analysis in Section 2, the larger the values of  $T_0$ ,  $S$ , and  $U$ , the better the mesh. Therefore, the larger the value of  $Q$ , the better the optoelectronic performance. Since the form of  $Q$  is simple, optoelectronic properties of any metallic mesh can be evaluated rapidly.

Next, we take SSMM as an example and use a typical CE method TOPSTIS to evaluate it. The result can be compared with the value of  $Q$  to verify its validity.

#### 4 TOPSIS comprehensive evaluation method based on the entropy weight

TOPSIS is a typical CE method and has no strict rules on the number of samples and the number of criteria or the distribution of data (Jahanshahloo et al., 2006; Shih et al., 2007; Yang and Hung, 2007; Krohling et al., 2015; Kuo, 2017). Because the metallic mesh has three important optoelectronic properties, TOPSIS is suitable for solving this complex multi-criterion evaluation problem. TOPSIS evaluates the properties of the alternatives through the similarity to the ideal solution. In the evaluation process, the relative weight of each criterion is determined objectively by EW, making the final evaluation result more reasonable and credible.

The specific steps of TOPSIS based on EW for SSMM are shown in the following subsections.

##### 4.1 Forming decision matrix

A decision matrix includes alternatives and criteria, and can be described by Eq. (4):

$$X = \begin{array}{c|ccc} & C_1 & \cdots & C_n \\ \hline A_1 & x_{11} & \cdots & x_{1n} \\ \vdots & \vdots & & \vdots \\ A_m & x_{m1} & \cdots & x_{mn} \end{array}, \quad (4)$$

where  $A_1$ – $A_m$  are viable alternatives ( $m$  represents the number of different design parameters for the metallic mesh),  $C_1$ – $C_n$  are criteria, with the three important optoelectronic properties mentioned in Section 3 as the criteria, with  $C_1=T_0$  (zero-order optical transmittance),  $C_2=S$  (EMI SE), and  $C_3=U$  (stray light uni-

formity), and  $x_{ij}$  indicates the value of  $C_j$  in the mesh alternative  $A_i$ .

In general, the criteria are classified into two types: benefit and cost. The benefit criteria are such that a higher value is better, while for cost criteria, the opposite is the case. In engineering applications, zero-order optical transmittance, EMI SE, and stray light uniformity are all benefit criteria.

Metallic meshes with high optical transmittance ( $T_0 \geq 90\%$ ) and strong shielding ( $S \geq 15$  dB) are appropriate in most transparent EMI shielding applications. We evaluate this kind of SSMM in this part. According to the calculation models of Kohin et al. (1993), with the actual fabricated linewidth  $2a$  not less than  $2 \mu\text{m}$  as the constraint condition, the design parameter range of the SSMM with high optical transmittance and strong shielding (SSMM-HTSS) is shown in Fig. 2a. In this range, each pair of  $g$  and  $2a$  for the SSMM satisfies the conditions of  $T_0 \geq 90\%$  and  $S \geq 15$  dB. Therefore, these parameter ranges constitute the area to be evaluated. To present the entire information of the whole evaluated area and reduce the calculation time, sampling points are evenly distributed in the area, as shown in Fig. 2b. There are 109 sampling points in Fig. 2b. These are the alternatives  $A_1, A_2, \dots, A_m$  in the decision matrix (4). The sampling linewidth and period interval are  $0.5$  and  $20 \mu\text{m}$ , respectively. Then all the evaluation criteria of different alternatives are calculated. Evaluation criteria for the alternatives when  $2a=2 \mu\text{m}$  are shown in Table 1.

##### 4.2 Normalizing the decision matrix

For the next step, the evaluation criteria of viable alternatives need to be turned into a comparable scale

**Table 1 Evaluation criteria for alternatives of SSMM when  $2a=2 \mu\text{m}$**

Alternative number	$T_0$ (%)	$S$ (dB)	$U$	$2a$ ( $\mu\text{m}$ )	$g$ ( $\mu\text{m}$ )
1	92.24	26.718	99.13	2	100
2	93.50	24.689	119.11	2	120
3	94.41	22.990	139.09	2	140
4	95.09	21.530	159.08	2	160
5	95.63	20.250	179.07	2	180
6	96.06	19.112	199.07	2	200
7	96.41	18.087	219.06	2	220
8	96.71	17.155	239.05	2	240
9	96.96	16.301	259.05	2	260
10	97.17	15.513	279.05	2	280

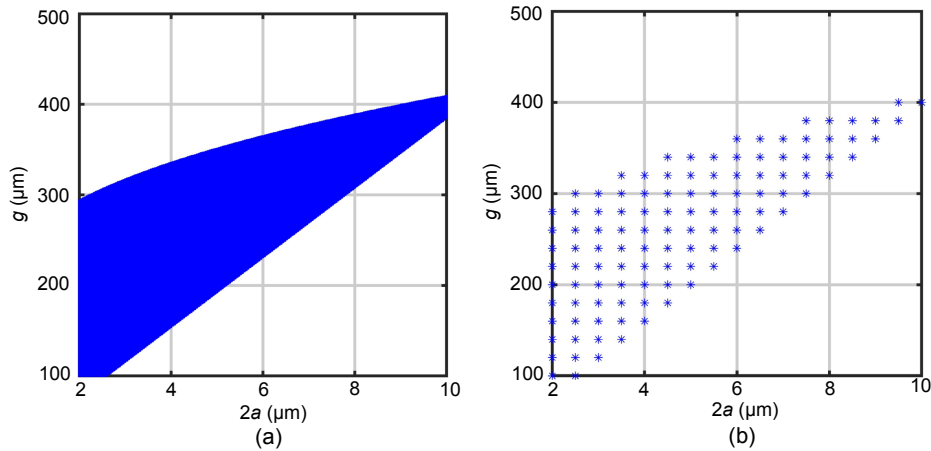


Fig. 2 Evaluation area (a) and evenly distributed sampling points (b) of SSMM-HTSS

by normalization. The normalized decision matrix  $H=(h_{ij})_{m \times n}$  is calculated as

$$h_{ij} = \frac{x_{ij}}{\sqrt{\sum_{i=1}^m (x_{ij})^2}}, \quad i = 1, 2, \dots, m, \quad j = 1, 2, \dots, n. \quad (5)$$

### 4.3 Constructing the weighted decision matrix by the entropy weight

EW is an objective weighting method (Zou et al., 2006; Zhang H et al., 2011; Ji et al., 2015), and the specific calculation steps are shown as follows:

First, the standardized matrix  $V=(v_{ij})_{m \times n}$  is obtained by standardizing the decision matrix  $X$ , which is shown in Eq. (6):

$$v_{ij} = \begin{cases} \frac{x_{ij} - \min(x_j)}{\max(x_j) - \min(x_j)}, & \text{benefit criteria,} \\ \frac{\max(x_j) - x_{ij}}{\max(x_j) - \min(x_j)}, & \text{cost criteria.} \end{cases} \quad (6)$$

From the standardized matrix  $V$ , the information entropy of the  $j^{\text{th}}$  criterion is defined as

$$e_j = -\frac{1}{\ln m} \sum_{i=1}^m p_{ij} \ln p_{ij}, \quad (7)$$

where

$$p_{ij} = \frac{v_{ij}}{\sum_{i=1}^m v_{ij}}. \quad (8)$$

From the concept of entropy, the greater the deviation degree of the  $j^{\text{th}}$  criterion is, the more information the criterion provides and the greater the weight of the  $j^{\text{th}}$  criterion is.

The weight of entropy for the  $j^{\text{th}}$  criterion could be defined as  $w_j$ , which forms the criterion weight matrix  $W=(w_j)_{1 \times n}$ :

$$w_j = \frac{1 - e_j}{n - \sum_{j=1}^n e_j}, \quad j = 1, 2, \dots, n. \quad (9)$$

From Eqs. (6)–(9), the objective entropy weight of the sample points is obtained. This is the relative weight of the evaluation criteria of SSMM-HTSS:

$$T_0 : S : D = 0.2724 : 0.3037 : 0.4239. \quad (10)$$

The weighted decision matrix on the basis of EW is constructed by multiplying the criterion weight matrix  $W$  by the normalized decision matrix  $H$  obtained in Section 4.2. The weighted decision matrix  $R=(r_{ij})_{m \times n}$  can be expressed as

$$r_{ij} = w_j h_{ij}, \quad i = 1, 2, \dots, m, \quad j = 1, 2, \dots, n. \quad (11)$$

### 4.4 Determining the positive ideal solution $S_j^+$ and negative ideal solution $S_j^-$

In this subsection,  $S_j^+$  and  $S_j^-$  can be obtained as the basis for calculating the separation.  $S_j^+$  indicates the most preferable alternative, while  $S_j^-$  indicates the

least preferable alternative.  $S_j^+$  and  $S_j^-$  are defined in terms of the weighted decision values, as shown in Eqs. (12) and (13), respectively:

$$S_j^+ = \{r_1^+, r_2^+, \dots, r_n^+\} = \left\{ (\max_i(r_{ij}) | j \in J_1), (\min_i(r_{ij}) | j \in J_2) | i = 1, \dots, m \right\}, \quad (12)$$

$$S_j^- = \{r_1^-, r_2^-, \dots, r_n^-\} = \left\{ (\min_i(r_{ij}) | j \in J_1), (\max_i(r_{ij}) | j \in J_2) | i = 1, \dots, m \right\}, \quad (13)$$

where  $J_1$  is associated with benefit criteria and  $J_2$  is associated with cost criteria.

#### 4.5 Calculating the separation

The separation between alternatives can be calculated by the  $n$ -dimensional Euclidean distance. The separation of each alternative from  $S_j^+$  is given as

$$Sd_i^+ = \sqrt{\sum_{j=1}^n (S_j^+ - r_{ij})^2}, \quad i = 1, 2, \dots, m. \quad (14)$$

Similarly, the separation of each alternative from  $S_j^-$  is given as

$$Sd_i^- = \sqrt{\sum_{j=1}^n (S_j^- - r_{ij})^2}, \quad i = 1, 2, \dots, m. \quad (15)$$

#### 4.6 Calculating the relative closeness to the ideal solution

The relative closeness of each viable alternative to the ideal solution  $S_j^+$  is defined as  $\eta_i$  in Eq. (16). The viable alternative is closer to the ideal solution with increasing  $\eta_i$ , which indicates a better evaluation result.

$$\eta_i = \frac{Sd_i^-}{Sd_i^+ + Sd_i^-}, \quad i = 1, 2, \dots, m. \quad (16)$$

From Eqs. (11)–(16), the relative closeness of 109 alternatives is obtained (Fig. 3). It can be seen that as the period increases, the relative closeness increases as well. When the period is similar, the relative closeness of each alternative decreases with

the increase of the linewidth. In brief, the largest period with the smallest linewidth for SSMM-HTSS reveals the best CE result. In addition, the optimal design parameters of SSMM-HTSS can be found at the position of the highest relative closeness value in Fig. 3: linewidth  $2a=2 \mu\text{m}$  and period  $g=280 \mu\text{m}$ . The corresponding optimal comprehensive optoelectronic properties are  $T_0=97.17\%$ ,  $S=15.513 \text{ dB}$ , and  $U=279.0468$ .

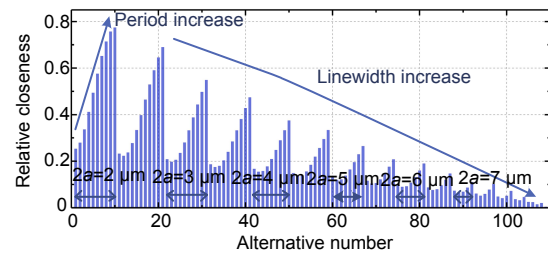


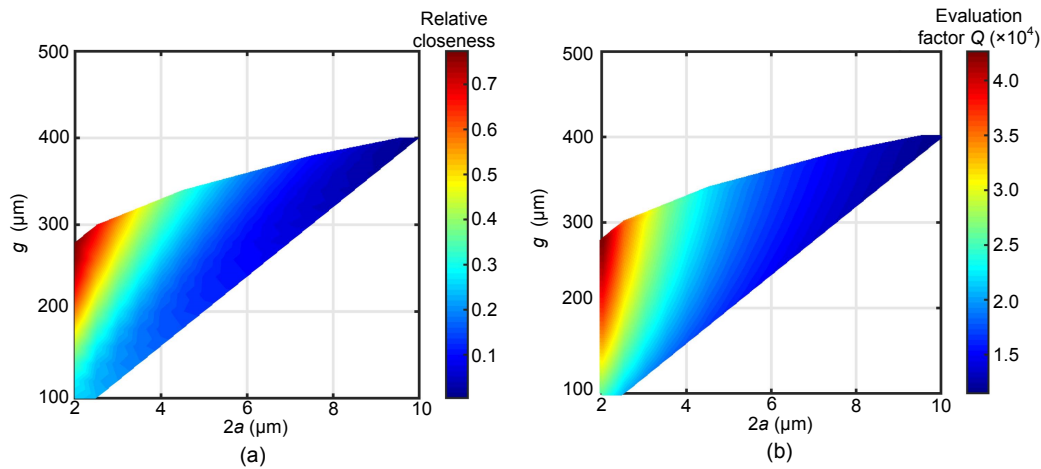
Fig. 3 Relative closeness bar chart of 109 SSMM-HTSS alternatives

For SSMM-HTSS, the relative closeness of mesh alternatives and the value of  $Q$  are compared under different design parameters, as shown in Fig. 4. The trend of the  $Q$  value agrees well with that of relative closeness, which shows that  $Q$  can represent the optoelectronic properties of the metallic meshes effectively.

### 5 Comparative evaluation of five different metallic meshes

The comprehensive evaluation factor  $Q$  can be used not only to evaluate different parameters of one kind of metallic mesh, but also to compare metallic meshes with different structures under various parameters. Table 2 shows the values of  $T_0$ ,  $S$ ,  $U$ , and evaluation factor  $Q$  of the five reported metallic meshes under the same fabricated linewidth ( $3.5 \mu\text{m}$ ) and zero-order optical transmittance ( $T_0=90.25\%$ ).

It can be seen that the value of evaluation factor  $Q$  for the ring metallic mesh is higher than that of the square metallic mesh. This indicates that the ring metallic mesh has better optoelectronic properties than the square metallic mesh, which is consistent with existing research findings (Tan and Lu, 2007). In addition, the values of  $Q$  for various complex metallic meshes in the literature designed to homogenize stray



**Fig. 4 Relationship between relative closeness and the design parameters of SSMM-HTSS (a) and between evaluation factor  $Q$  and the design parameters of SSMM-HTSS (b)**

**Table 2 Comprehensive evaluation factor  $Q$  for five different metallic meshes**

Metallic mesh	$T_0$ (%)	$S$ (dB)	$U$	$Q$	Reference
Square metallic mesh	90.25	26.92	102.26	2484.437	Kohin et al. (1993)
Ring metallic mesh	90.25	22.08	225.78	4499.163	Tan and Lu (2007)
Nested multi-ring array metallic mesh	90.25	20.13	535.42	9727.149	Wang HY et al. (2017)
Triangular ring mesh with rotated sub-rings	90.25	20.69	670.96	12 528.65	Lu ZG et al. (2016)
Interlaced multi-ring metallic mesh	90.25	21.42	960.93	18 576.27	Lu X et al. (2019)

light are higher than that of the ring metallic mesh. The interlaced multi-ring metallic mesh has the highest value of  $Q$  among the five different metallic meshes (Lu X et al., 2019). Therefore,  $Q$  is applicable for evaluation of differently shaped meshes, providing guidance for the selection of mesh types in engineering applications.

## 6 Conclusions

In this paper, we proposed a comprehensive evaluation factor  $Q$  constructed from the three main criteria for metallic mesh, i.e., zero-order optical transmittance, EMI SE, and stray light uniformity.  $Q$  can be used to quantitatively evaluate the optoelectronic properties of the metallic mesh with different parameters. The trend of the relative closeness obtained by evaluating the SSMM using the method of TOPSIS based on EW agreed well with the trend of  $Q$ , which shows the efficacy of  $Q$ . We also used  $Q$  to evaluate five different metallic meshes at the same fabricated linewidth and optical transmittance, which shows that  $Q$  is suitable for evaluating meshes with

different shapes.  $Q$  can be extended to the application to the evaluation of multi-layer meshes. Because of its simple form and direct relation to optoelectronic property criteria,  $Q$  can be used to evaluate the optoelectronic properties of meshes with any structure or parameters quickly and comprehensively. Thus, it should be of great significance in the design and application of conductive metallic meshes.

## Contributors

Zhengang LU designed the research. Yilei ZHANG performed the simulations and drafted the manuscript. Jinxuan CAO processed the data and gave suggestions for the verification methods. Heyan WANG and Jiubin TAN helped organize the manuscript. Yilei ZHANG and Zhengang LU revised and finalized the paper.

## Compliance with ethics guidelines

Yilei ZHANG, Jinxuan CAO, Zhengang LU, Heyan WANG, and Jiubin TAN declare that they have no conflict of interest.

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